## Possible Localization B ehavior of the Inherent C onducting P olymer $(CH_3)_{0.9}R \in O_3$

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## A bstract

Polymericm ethyltrioxorhenium (poly-MTO) represents the rst example of an inherent conducting organom etallic oxide. It adopts the structural motives and transport properties of some classical perovskites in two dimensions. In this study we present resistivity data down to 30 mK which exhibit a crossover from a metallic (d /dT > 0) to an insulating (d /dT < 0) behavior at about 30 K.Below 30 K an unusual resistivity behavior, sim ilar to that of some doped cuprate systems, is observed: initially the resistivity increases approximately as log (l=T) before it starts to saturate below 2K.Furtherm ore, a linear positive magnetoresistance is found (up to 7T).Tem perature dependent magnetization and speci cheat measurem ents in various magnetic elds indicate that the unusual resistivity behavior may be driven by spatial localization of the d<sup>1</sup> m om ents at the Re atom s.

K ey words: O rganom etallic hybrids, m etal{insulator transition, localized state PACS: 71.20 RV; 71.30.+ h; 71.70 M S  $\,$ 

Polymeric m ethyltrioxorhenium (poly-M TO),  $f(CH_3)_{0:9}ReO_3q_1$ , is a unique representant of a conductive organom etallic polymer in metal-oxide systems, with a moderate high resistivity of 6m cm at room temperature [1]. The conductivity is attributed to a fraction of dem ethylated Re atom s. Instead of a crossover from a Re(VII) (d<sup>0</sup>) to a Re(VI) (d<sup>1</sup>) state, these dem ethylated R e atom s are e ectively oxidized and their electrons are transferred to the band system . Only a minor part (0.05% Re atom s [2]) remains located at the metal sites which are in the following treated as Re(d1) centers. They model a two dim ensional dilute m etal-oxide spin system . The attempt to increase the electronic conductivity of poly (M T O by em ploying the organic donor species tetrathiafulvalene

(TTF) leads to a crossover from m etallic to insulating behavior with increasing TTF contribution [2].

The resistivity of poly (M TO at low tem peratures and in high magnetic elds within the ReO<sub>2</sub> planes resembles of the CuO<sub>2</sub> planes of the Zn (doped high {T<sub>c</sub> superconductor Y Ba<sub>2</sub>Cu<sub>3</sub>O<sub>7</sub> (Y BCO) [3]. The scattering centers in Zn (doped Y BCO) are due to nonmagnetic Zn centers in the antiferrom agnetic spin correlated CuO<sub>2</sub> planes. The scattering centers of poly { M TO m irror the inverse situation: them agnetic d<sup>1</sup> centers are placed in nonm agnetic ReO<sub>2</sub> planes. Therefore poly {M TO m ight be a prom ising candidate to revitalize the discussion about the electron scattering m echanism in cuprates.

Poly-M TO was synthesized by auto-polym erization of MTO in ux at 120 C during 48 h [2].X -ray powder di raction m easurem ents suggest a two-dim ensional fR eO  $_{2}g_{1}$  layered structure. The m issing 001 series and the asym m etric shape of the hkO re ections indicate ordering to occur solely in two dim ensions.

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Fig. 1. (a) Resistivity vs. logT in various magnetic elds B. The solid lines are logarithm ic ts between 5K and 30K and power{law tsbelow 2.5K ( / T with = 0.2; 0.4; 0.5; 0.5for B = 0; 3; 5; 7T, respectively). (b) Above 80K the resistivity obeys a power{law / T <sup>1:5</sup>. (c) A positive magnetoresistivity is observed, sim lar to that seen in Ref. [3].

Figs.1 a,b show the resistivity of (C H  $_3$ ) $_{0:9}$ R eO  $_3$  on a sem i{logarithm ic and linear tem perature scale, respectively. The high residual resistivity m ay be due to interlayer disorder [2]. The tem perature dependence of the resistivity clearly exhibits a crossover from a m etallic (d /dT > 0) to an insulating (d /dT < 0) behavior at about 30 K .B elow 30 K a log (1=T) divergence over one decade of T is observed, sim ilar to that found in Zn{ doped YBCO [3]. At low est tem peratures a crossover to a power{law dependence is detected, / T , with

 $0.5~{\rm for}~B>3T$  . In the insulating regime we observe a positive, linearly increasing m agnetoresistivity as depicted for two tem peratures in Fig.1c.

Common scenarios predicting a log(1=T) behavior like conventional K ondo im purities or 2D weak localization, cannot explain our experimental results. In both cases the logarithm ic divergence of the resistivity should be reduced in the presence of a magnetic eld.

For further inform ation concerning the origin of the positive linear m agnetoresitivity, tem perature dependentm agnetization m easurem ents in various m agnetic elds B were perform ed. In Fig. 2 a the m agnetization M divided by the applied magnetic eld B is plotted vs.tem perature. The solid lines are ts, which follow a Brillouin function, assuming that the param agnetic behavior is only due to independent d<sup>1</sup> m om ents with a quenched orbital m om ent. The two t param eters, the amount of  $Re(d^1)$  centers and the constant it in erant contribution  $_{0} = _{Pauli} + _{Landau}$ , are pictured in Figs. 2b and c, respectively. These two plots show clear evidence, that with increasing magnetic eld, the am ount of localized d<sup>1</sup> m om ents increases linearly with a sim ultaneous decrease of the itinerant electrons. This spatial localization of the d<sup>1</sup> m om ents at the R e atom s m ight be the origin of the unusual linear positive m aqnetoresitivity in poly (M TO.



Fig. 2. (a) M =B of poly (M TO in several external magnetic elds. The solid lines are Brillouin-ts for a d<sup>1</sup> m om ent using the amount of Re(d<sup>1</sup>) centers (b) and  $_0$  (c) as t parameters.

This interpretation is also corroborated by the m agnetic eld dependence of the internal electric eld gradient ( $V_{zz}$ ) at the R e site. A nalysis of speci cheat data below 1K with a crystal eld model reveals a decrease of the R e nuclear quadrupole splitting with increasing magnetic eld B, pointing to a decrease of  $V_{zz}$ . This indicates a reduction of the electronic and structural anisotropy at the R e site, which is in good agreement with density functional theory (DFT) geometry optimization of poly (MTO, where an increasing amount of localized d<sup>1</sup> centers leads to a reduction of strain in the ReO<sub>2</sub> planes [4].

The origin of the log(1=T) and T dependence of could be the Altshuler(A ronov [5] correction in the presence of a crossover from 2D to 3D di usion at lower tem perature. In a granular system a similar crossover is also expected between the high tem perature incoherent tunnelling and the low tem perature coherent intergrain tunnelling [6]. But at present we cannot exclude K ondo{like scenarios. In this respect we notice that the spatial localization of the d<sup>1</sup> m om ents in the R eO<sub>2</sub> planes m ight be a new approach for the understanding of the unusual resistivity of Zn-doped Y BCO.

## A cknow ledgem ent

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